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exposing the photosensitive layer to light through a mask, said mask comprising a pattern of horizontal lines and vertical lines, wherein the horizontal lines define a plurality of parallel linear barriers, and wherein the vertical lines [defines] define a plurality of raised portions extending substantially perpendicularly between adjacent barriers and formed lower than said barriers; and

etching [the barrier material layer] perpendicularly between the barrier material layer to form said plurality of cells.

## **REMARKS**

Pursuant to a telephone conversation conducted on November 27, 2000, the Examiner provided suggestions in amending the instant application to overcome the prior art. Applicant respectfully thanks the Examiner for providing these suggestions and has amended independent claims 1, 12, and 14 and the specification accordingly. Independent claims 1 and 12 have been amended to include structure that follows from Fig. 5 illustrating that raised portions 103 formed on one substrate fail to extend to contact the opposite substrate. Independent claim 14 has been amended to include structure stating that these raised portions extending from one substrate are formed lower than the barrier material, which contacts the other substrate. Applicant submits that independent claims 1, 12, and 14 are allowable.

Because claims 2-11 and 13 depend from either of independent claims 1 and 12,

Applicant submits that they are allowable for at least the same reasons given above.

The specification has also been amended to include the subject matter shown in Fig. 5 and disclosed in the claims. Applicant submits that no new matter has been added by this amendment.

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Attorney Docket No. 4931.0039-00

In view of the foregoing amendments and remarks, Applicant respectfully requests the reconsideration and reexamination of this application and the timely allowance of the pending claims.

Please grant any extensions of time required to enter this response and charge any additional required fees to our deposit account 06-0916.

Respectfully submitted,

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Dated: December 1, 2000

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